

Transient Modeling of Ferroelectric Capacitors for Semiconductor Memories

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Abstract: Present ferroelectric (FE) capacitor models mostly rely on continuous hysteresis loop characteristics of FE materials. Our experimental results show that this approach overestimates the remanent and saturation polarizations available for nonvolatile semiconductor memories by more than 50%. A behavioral transient model based on pulse measurement results is proposed and implemented as an HSPICE macro-model. The model mainly consists of two nonlinear capacitors, corresponding to the two different polarization states of an FE capacitor.

I. INTRODUCTION

Ferroelectric (FE) capacitors have long been recognized as suitable storage elements for nonvolatile memory cells [1-2]. Low density FRAMS (such as 512×8b and 4k×8b) are now commercially available and compete with both EEPROMs and battery-backed SRAMs [3]. Higher density FRAMs (such as 32k×8b, 100ns access time) have been successfully designed and tested [4], and the search continues to provide higher density FRAMs with faster read/write time and higher reliability. Meanwhile, FE circuit simulation and optimization are hindered by a lack of accurate CAD circuit models. As a result, current design methods are primitive, and FE circuits are usually designed and margined independently of the actual transient characteristics of the FE capacitor. In fact, the best modeling techniques used presently in memory circuit simulation for this technology only provide for static DC modeling; few transient models have yet been proposed [5].

The complex behavior of an FE capacitor in response to arbitrary voltage patterns is perhaps the main difficulty towards universal modeling of this element. From the circuit point of view, the FE capacitor is a nonlinear element with memory and, hence, has the complexity of both. A nonlinear *but memoryless* capacitor can be modeled behaviorally by a piecewise linear curve in the Q-V plane (charge vs. applied

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voltage). In any voltage interval bounded by two consecutive breakpoints, the nonlinear capacitor would be equivalent to a series combination of a linear capacitor and a voltage source. The accuracy of such model depends on the number of breakpoints chosen in approximating the nonlinear curve, that is, the more breakpoints the more accurate the model. A nonlinear *with memory* capacitor, on the other hand, is modeled by several piecewise linear curves. Each curve represents a nonlinear capacitor corresponding to a state of the capacitor memory. It is evident, therefore, that the larger the memory depth (the number of memory states), the more complex the model. In fact, the number of measurements required for behavioral modeling of a nonlinear device is equal to the number of breakpoints chosen to approximate a nonlinear characteristic multiplied by the number of states.

For an FE capacitor, the number of states can be very large if a general model is intended. However, only a few states need to be considered if modeling is employed for conventional memory applications such as a 1T-1C FRAM cell. Figure 1 shows the circuit diagram of a 1T-1C memory cell activated through wordline, and written or read through bitline and driveline. In writing a binary digit 0 to the cell, a positive voltage (normally the full power supply, V_{DD}) is applied to the bitline while the driveline is grounded and the wordline is asserted. The voltage waveform that appears across the capacitor is a positive square pulse with amplitude $V_{DD}-V_T$, where V_T is the threshold voltage of the access transistor. In writing a binary digit 1, a positive voltage (V_{DD}) is applied to the driveline while the bitline is grounded and the wordline is asserted. The voltage waveform across the capacitor in this case is a negative pulse with amplitude V_{DD} . The voltage waveforms for the read operations are also pulses with similar rise and fall times but with possibly different amplitudes [6]. For example, in [6] it is explained that the capacitor can also experience $2/3 V_{DD}$ depending on the read-write sequence. It is this limited variety of pulse amplitudes that helps simplify the behavioral modeling of FE capacitors for memory applications.

In this paper, we illustrate a modeling procedure based on the above approach. For simplicity, only two distinct polarization states are considered in these examples. However, the procedure is easily extensible to modeling with a larger number of states. Figure 2 depicts the two polarization states on a hysteresis loop along with its corresponding state transition diagram. According to this diagram, the next state of the capacitor is determined by its current state and the polarity of the applied pulse. The capacitor remains in the positive polarization state if the input pulse has a positive polarity, or changes to a negative state if the input pulse has a negative polarity. Similarly, the capacitor remains in the negative polarization state if the input pulse has a negative polarity, or changes to a positive state if the input pulse has a positive polarity.

A two-state transition diagram forms the basis of our proposed model. Accordingly, it consists of two distinct parts, corresponding to two distinct states, and an algorithm that dictates switching from one state to another depending on the input pulse polarity. In sections II and III of this paper, we discuss the details of an experimental procedure that leads to the construction of each part. Next, in Section IV, we propose

the model by incorporating the experimental results into the state transition diagram. As we will see in the same section, such a model easily lends itself to an HSPICE macro-model implementation. Finally, some simulation results generated by this model will be presented.

II. EXPERIMENTAL PROCEDURE

There are two types of circuits that are used for behavioral characterization of an FE capacitor: The Sawyer-Tower circuit and the pulse measurement circuit [1-2]. The Sawyer-Tower circuit is normally used to record the hysteresis loop of an FE capacitor, that is, the polarization variation in response to a low-frequency, sinusoidal voltage waveform. The hysteresis loop illustrates a periodic switching of polarization in response to an applied periodic voltage waveform. On the other hand, the pulse measurement circuit is used to record the transient current of an FE capacitor in response to non-periodic, one-shot pulses with short durations (on the order of the circuit time constant). As such, the pulse measurement results convey much more information with regard to FE memory design where the capacitor experiences one-shot read/write pulses with short durations. At the same time, the pulse measurement procedure is more involved, and requires special considerations. We present some of these considerations through the description of our measurement setup.

Our hysteresis loop measurement setup is a Sawyer-Tower based circuit with a 10 nF integrating capacitor. A continuous 1KHz sinusoidal waveform is applied to the circuit and the voltage across the integrating capacitor is monitored by a 300MHz, 1Gs/sec digitizing oscilloscope. The charge on the 10 nF capacitor at the peak value of the input waveform is divided by the FE capacitor area to find the polarization parameter P_s . Similarly, the charge corresponding to the zero value of the input waveform is divided by the FE capacitor area to find P_r .

The pulse measurement circuit consists of a series combination of an FE capacitor and a small resistor. As shown in Figure 3, the circuit is driven by a programmable pulse generator through a coaxial cable. All coaxial cables used in this setup have 50 Ω intrinsic impedances and are terminated at one end by a 50 Ω resistor. This eliminates signal reflections from the terminal nodes (i.e. the scope channels and the pulse generator terminal). This consideration is particularly important for transient measurements, as the delay produced by the cable is comparable with the signal rise time. The signal delay per unit length (one meter) of the cable is 5 nanoseconds while the signal rise time is only 1.8 nanoseconds. Therefore, the reflected signal would be in the period of interest for the transient analysis. For a fully matched setup, there are no reflections from the scope terminals. The signals captured by the scope are only delayed versions of signals at nodes X and Y. These delays can be made equal by using the same length for both cables. On the other hand, the signal reflections from the capacitor nodes are unavoidable due to both capacitive and nonlinear

characteristics of the FE capacitors. In fact, even if the FE capacitor were replaced by a perfectly linear resistor, the signal reflections from node A would still occur.

We have used FE capacitor samples (PZT: Zr/ Ti = 40/60) from two different vendors, which we refer to as capacitor C_A and capacitor C_B throughout this paper. Capacitor C_A is $80 \times 80 \mu m^2$ while capacitor C_B is $100 \times 100 \mu m^2$ in size. Since the RC time constants of the measurement circuit in these two cases are unequal, two different sets of pulse durations are chosen for the small and the large size capacitors. The pulse durations are not critical in our measurements provided they are long enough to ensure any transients have died down within these time periods. The voltage pattern is shown in Figure 4. The initial negative pulse brings the capacitor to its negative state (refer to Figure 2). After a few seconds, which is the time required for the computer to initialize the pulse generator, two positive pulses are applied. The first positive pulse stimulates both the switching and the nonswitching current to flow through the capacitor. The second positive pulse only stimulates the nonswitching current [7].

The experiment is repeated 20 times, using 20 different pulse amplitudes uniformly distributed between zero volts and the full supply voltage. To limit the maximum field applied to our capacitor samples of 2500 Angstroms thickness, 10V is chosen as the maximum pulse amplitude voltage.

The measurement results are expected to be repeatable, if both the thickness and the voltage amplitude are scaled down by the same factor. In fact, the electric field remains unchanged by these scalings. Meanwhile, note that the film thickness cannot be reduced beyond a limit imposed by the process yield.

III. RESULTS AND DISCUSSIONS

Three parameters of interest to ferroelectric nonvolatile memory design are the remanent polarization, the saturation polarization, and the switching time of the FE capacitor. The first two parameters can be derived from both hysteresis loop and pulse measurements whereas the last parameter can only be derived from pulse measurements. It will be shown in this section that the hysteresis loop based polarization can overestimate these parameters by more than 50%. The switching time is argued to be negligible in comparison with the RC time constant of a minimum size FE memory cell.

Two sets of experimental results are shown in Figure 5. Part (a) of the figure shows the transient current of capacitor C_A corresponding to the first and the second positive pulses as captured by channel B of the scope. Part (b) shows similar results for capacitor C_B . Comparing parts (a) and (b), the transient current of capacitor C_A overshoots while the other one decays smoothly to zero. The main reason for this difference lies in the relative sizes of the capacitors. The measurement circuit is an effective RLC circuit due to the inductance of the probe tips. Such a circuit can cause three types of behavior, namely: underdamped behavior (oscillatory response), critically damped behavior, and overdamped behavior (non-oscillatory response). An oscillatory response is caused by capacitances less than a critical value, determined by the

series resistance and inductance in the measurement circuit. Likewise, non-oscillatory response is caused by capacitances greater than the critical value. In our measurement circuit, the capacitance value of capacitor C_A (C_B) happens to be below (above) the critical value. Therefore, capacitor C_A (C_B) shows oscillatory (non-oscillatory) transient behavior. It is expected, however, to observe non-oscillatory transient currents for capacitor C_A with larger areas. It is also expected to observe non-oscillatory results if less inductive probe tips are used in the measurement.

Despite the transient current dependence on the inductance value in a series RLC circuit, the final charge stored on the capacitor is independent of the inductance value and can be calculated by integrating the transient current over the pulse interval. Referring to Figure 5(a), the integral of the first pulse current over the interval (50 ns, 150 ns) represents the sum of the switching and the nonswitching charge of C_A , while the integral of the second pulse current over the same interval represents only the nonswitching charge of C_A . We denote by P_1 and P_0 , respectively, the integral of the first and second pulse currents over the mentioned period divided by the FE capacitor area. The integrals are calculated numerically using the trapezoidal method. Similarly, P_1 and P_0 are calculated for C_B with (100 ns, 400 ns) as the time interval (refer to Figure 5(b)). Note that P_1 (the available polarization increment for the digital 1 state) corresponds to the P_s+P_r while P_0 (the available polarization increment for the digital 0 state) corresponds to the P_s-P_r of the hysteresis loop (refer to Figure 2). P_s and P_r can be expressed in terms of P_1 and P_0 by the following equations:

$$P_s = \frac{1}{2}(P_1 + P_0) \quad \& \quad P_r = \frac{1}{2}(P_1 - P_0) \quad (1)$$

The switching time measurement, on the other hand, is quite sensitive to the inductance value, especially when the ferroelectric capacitance is comparable to its critical value. In short, the capacitor size is not of critical importance as far as the remanent and the saturation polarizations are concerned. For the switching time measurements, it is important to choose smaller capacitors and AC probe tips with less inductance.

Based on the above arguments, the polarization parameters, P_1 and P_0 , are the only valid data that can be extracted from our pulse measurement results. These parameters are extracted as functions of the pulse amplitude and compared with their corresponding values derived from hysteresis loop measurement in Figure 6. Part (a) of this figure compares P_1 and P_0 for capacitor C_A as derived from pulse measurements (dashed curves) with their counterparts derived from hysteresis loop measurements (solid curves). Part (b) of this figure illustrates similar parameters for capacitor C_B .

First, note that the polarization values for capacitor C_B are at least twice as high as the polarization values for capacitor C_A . At 8 V pulse amplitude, for example, P_1 and P_0 for capacitor C_B are 2.5 and 2.6 times their corresponding values for capacitor C_A . Also note that at the same input voltage P_r is 4 times larger for capacitor C_B . These are two significant advantages of capacitor C_B .

Second, note that the polarization parameters for capacitor C_B saturate at around 10 V while capacitor C_A behaves almost linearly in the same range. This indicates that higher polarization values are achievable by capacitor C_A at higher voltages. Higher polarizations can also be obtained by reducing the thickness in capacitor C_A .

Finally, note that the hysteresis loop characteristic overestimates P_1 by 85% and 104% for capacitors C_A and C_B , respectively. This overestimation is caused by the longer period of the applied signal (1 ms instead of 100 ns) as well as its periodicity.

A. Switching Time

The switching speed of a ferroelectric capacitor from one polarization state to another is a figure of merit for the capacitor in nonvolatile memory applications. This speed is normally characterized by the switching time of the capacitor. In this section, we investigate practical limitations in the measurement of this parameter.

Switching time is defined as the time required for a constant applied voltage to switch the polarization state of the capacitor. In practice, switching time is difficult to measure, since it is much smaller than both the RC time constant of the measurement circuit and the rise time of the applied pulse. In fact, by the time the voltage across the capacitor is constant, the switching has already been completed. Therefore, it remains ambiguous as to what fraction of this time is due to the intrinsic switching time and what fraction is due to the pulse rise time and the RC time constant. A study by Larsen et. al. on PZT capacitors [8] demonstrates the switching time as a function of the capacitor area. As the area of the capacitor decreases (equivalent to reducing the RC time constant of the circuit), the measured switching time decreases. If this function is extrapolated to where the capacitor area is zero, a switching time of 1.8 nanoseconds can be predicted. This value is exactly equal to the rise time of the applied pulse. Therefore, the switching time measurement is restricted by the pulse rise time, which is an instrument limitation. The inherent switching time (i.e. the switching time when not restricted by the circuit RC time constant and the instrument limitation) is expected to be around 100 picoseconds [9]. This time is at least one order of magnitude less than the typical RC time constant of a one-transistor memory cell (refer to Figure 1). In 0.8 micron CMOS technology, for example, such time constants are around 10 nanoseconds, assuming a 1 pF bitline capacitance and 2:1 ratio for the bitline capacitance to the cell capacitance [6].

Based on the above arguments, we neglect the switching time in comparison with the RC time constant of the cell. The following calculation shows that this approximation underestimates the memory access time by less than 10% if the number of cells per bitline is greater than 10. Each cell typically contributes 4 fF to the bitline capacitance, including the diffusion and the metal parasitic capacitances. For 10 cells, the total capacitance on the bitline will be 40 fF. The 2:1 ratio [6] results in 20 fF for the FE capacitor and,

hence, 300 picoseconds for the RC time constant. Assuming 15 k Ω as the access transistor ON resistance and a minimum of three time constants for the signal development time, the access time exceeds 900 picoseconds. This must be compared with 1000 picoseconds if the switching time is included. This error reduces to 0.78% in a 128 cells per bitline memory and 0.39% in a 256 cells per bitline memory.

Assuming zero switching time, on the other hand, greatly simplifies the transient analysis of the ferroelectric capacitor. It also reduces the measurement complexity that otherwise is required. We present this analysis in the next section where we will introduce our proposed model.

IV. ZERO SWITCHING -TIME TRANSIENT (ZSTT) MODEL

In the last section, we mentioned that the switching time of the FE capacitor can be neglected in comparison with the RC time constant of an FE memory cell. The transient model introduced in this section is based on this assumption and, therefore, called the ZSTT Model. Zero switching-time implies that the charge increment on the FE capacitor will reach its final value instantaneously¹. Therefore, the charge increment is only a function of the applied voltage and the initial state of the capacitor, not a function of time. In other words:

$$\Delta Q = \Delta Q(V, Q_{init}) \quad (2)$$

where V and Q_{init} represent the applied voltage and the initial polarization charge on the capacitor. Since there are only two initial states that are important to a memory cell (i.e. digital 0 and 1), the above equation can be broken into two parts, each corresponding to one initial state. In other words:

$$\Delta Q = \begin{cases} \Delta Q_0(V) & \text{for digital 0 state} \\ \text{or} \\ \Delta Q_1(V) & \text{for digital 1 state} \end{cases} \quad (3)$$

Each part of Equation 3 represents, in general, a nonlinear function of voltage that must be determined. Let us first determine ΔQ_0 . A digital zero state is defined to be the positive polarization state of the capacitor. A positive voltage, in this case, results in a polarization increment of P_0 (or equivalently $P_s - P_r$) whereas a negative voltage results in a charge decrement of P_1 (or equivalently $P_s + P_r$). Recall from the last section that both of these parameters are functions of the applied voltage and can be determined experimentally. Also note that a polarization increment is equivalent to a charge increment if multiplied by

1. Although an instantaneous charge increment implies an infinite current, this never occurs in a practical circuit. This is because the current is always limited by an external resistance such as the ON resistance of the access transistor.

the capacitor area. Therefore, ΔQ_0 can be expressed as a function of P_s , P_r , and the capacitor area by the following equation:

$$\Delta Q_0(V) = A\{P_s(V) - P_r(V)\}u(V) + A\{P_s(V) + P_r(V)\}u(-V) \quad (4)$$

where A represents the capacitor area and $u(V)$ represent the unit step function. In this equation, we have assumed both P_s and P_r are odd functions of the applied voltage. Cases in which this assumption is not valid can be treated by minor modifications. Equation 3 can be further simplified as:

$$\Delta Q_0(V) = A\{P_s(V) - \text{sgn}(V)P_r(V)\} \quad (5)$$

where $\text{sgn}(V)$ represents the signum function that is equal to -1 for negative values and +1 for positive values of V . A similar argument for the digital 1 state results in:

$$\Delta Q_1(V) = A\{P_s(V) + \text{sgn}(V)P_r(V)\} \quad (6)$$

Equations 5 and 6 form the basis of the ZSTT Model. The accuracy of these equations depends on the accuracy of the two functions $P_s(V)$ and $P_r(V)$ that are determined by curve fitting to the experimental data. Therefore, their accuracy depends on the number of data points as well as the measurement accuracy. When there is a sufficient number of data points, measurement accuracy is the limiting factor in the overall accuracy.

The experimental results for capacitor C_A and C_B presented in the last section can be directly substituted into Equations 5 and 6 to determine ΔQ_0 and ΔQ_1 for each capacitor. Since 20 data points are used between 0 and 10 V, such a direct substitution results in a piecewise linear function with 37 breakpoints between -10 and 10 V. However, simple inspection of Figure 6(a) reveals that P_1 and P_0 for capacitor C_A can be approximated by two straight lines if a 5% error is tolerable. As a result of this approximation, ΔQ_0 and ΔQ_1 have only one break point at the origin (Figure 7(a)). A tolerance of 5% for P_1 and P_0 of capacitor C_B results in piecewise linear functions having 2 break points between 0 and 10 V or, equivalently, 5 break points in the full domain of ΔQ_0 and ΔQ_1 . These functions are shown in Figure 7(b).

The piecewise linear approximation of $\Delta Q_0(V)$ and $\Delta Q_1(V)$ results in two piecewise linear capacitors that can be implemented in most circuit simulators. We present an HSPICE implementation of the model in the next section.

A. Model Implementation

A circuit representation of the ZSTT Model is shown in Figure 8. $C_0(V_0)$ and $C_1(V_1)$ represent the two nonlinear capacitors corresponding to the two binary states of the FE capacitor (discussed in the last section). If the binary state of the FE capacitor is 0, switches S_{01} and S_{12} are closed while switches S_{11} and S_{02} are open. In this case, the equivalent capacitance looking into the input terminals is $C_0(V_0)$. Meanwhile, a voltage controlled voltage source, which is equal to V_i , is connected to $C_1(V_1)$ to initialize

this capacitor for the opposite binary state. For binary state 1, the states of the switches are the reverse: switches S_{11} and S_{02} are closed while switches S_{01} and S_{12} are open. Therefore, the capacitance looking into the input terminals is $C_1(V_1)$, and the controlled source is connected to $C_0(V_0)$ for the similar reason mentioned above.

If the initial binary state of an FE capacitor is known, its subsequent binary states can be determined by the applied pulse pattern. A binary state 0 remains unchanged in response to a positive pulse as well as the leading edge (falling edge) of a negative pulse. It only changes on the trailing edge (rising edge) of the negative pulse. A binary state 1 remains unchanged in response to a negative pulse as well as the rising edge of a positive pulse. It only changes on the falling edge of the positive pulse. One example of an input voltage pattern and its corresponding control signals for the switches are illustrated in Figure 9. The initial binary state of the capacitor, in this example, is considered to be 0. Therefore, S_{01} and S_{12} are initially closed, and the equivalent capacitance looking into the input terminals is $C_0(V_0)$. On the rising edge of the first negative pulse, switches S_{11} and S_{02} are closed and switches S_{01} and S_{12} are opened. In this case, the capacitance looking into the input terminals is $C_1(V_1)$. This situation will be reversed again on the falling edge of the first positive pulse.

The ZSTT Model can be easily implemented as an HSPICE macro-model if the two nonlinear capacitors in Figure 8 are replaced by their piecewise linear approximations. The switches can be replaced by voltage-controlled resistors (VCRs) that exhibit high and low resistances for the open and closed states of the switches, respectively. The controlling voltages for these switches can be derived by the method described above.

V. SIMULATION RESULTS

The ZSTT transient Model can be used to simulate the electrical behavior of an integrated FE capacitor in any of the standard memory configurations. In this section, we present an example of such a simulation. In particular, we use this model in conjunction with the 1T-1C FE memory cell (Figure 1) to simulate an FRAM read operation.

A typical decision that must be made during the course of any FRAM design is the selection of an appropriate capacitor area given certain design parameters. A transient simulation of a read operation is useful in making this selection. We wish to determine (for capacitors C_A and C_B) the area that results in an identical 100 mV differential signal on a 1-pF bitline.

As mentioned earlier, capacitors C_A and C_B were fabricated for test purposes. The dielectric thickness, in both cases, is optimized for 10 V supply operation. However, it is expected that the capacitors would behave similarly if the thickness was decreased for 5 V supply operation. Therefore, we assume that the horizontal axes in Figure 6 can be scaled down to 5 V without changing the polarization parameters.

As shown in Figure 10, the wordline (WL) and driveline (DL) in both designs are driven by identical pulses, having 1 ns rise time. The capacitor sizes are then optimized, an incremental process requiring several simulation runs, to obtain the same differential voltage (100 mV) on the bitline for the digital 1 and 0 stored data. The scaled sizes are predicted to be $11 \mu\text{m}^2$ and $5 \mu\text{m}^2$ for capacitor C_A and C_B , respectively. Therefore, an area saving of 54% is expected by using vendor B capacitors. Figure 10 illustrates the final simulation results.

VI. SUMMARY

In this paper, we described the experimental procedure for device characterization of ferroelectric capacitors. Our experimental results show that the continuous hysteresis loop characteristic overestimates the remanent and saturation polarizations available for a nonvolatile memory by more than 50%.

The switching time of the ferroelectric capacitor can be neglected in comparison with the RC time constant of a memory cell. Based on this argument and pulse measurement results, a new transient model (the Zero Switching-Time Transient Model) was proposed and implemented as an HSPICE macro-model. The model was used to optimize the capacitor sizes for a read operation in a 1T-1C FRAM design.

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FIGURES

Captions

Figure 1: A 1T - 1C FRAM Cell

Figure 2: (a) Hysteresis Loop employed as a polarization state diagram, (b) State Transition Diagram for a two-state capacitor model

Figure 3: Pulse measurement circuit diagram

Figure 4: The pulse pattern applied to the pulse measurement circuit (Fig. 3). The dotted lines represent several seconds of delay between two consecutive pulses, as required to setup the instruments for each measurement.

Figure 5: The transient currents associated with the first and second positive pulses (Fig. 4) for capacitors (a) C_A and (b) C_B .

Figure 6: Hysteresis loop based polarizations (solid curves) versus the transient based polarizations (dashed curves) for capacitors (a) C_A and (b) C_B .

Figure 7: The characteristics of the two nonlinear capacitors representing capacitors (a) C_A and (b) C_B in the ZSTT Model.

Figure 8: An implementation of the ZSTT Model.

Figure 9: A sample voltage pattern across the FE capacitor and its corresponding control signals for switches in the ZSTT Model.

Figure 10: HSPICE simulation results for the read operation of a 1pF-bitline FRAM using optimized sizes of capacitors C_A and C_B

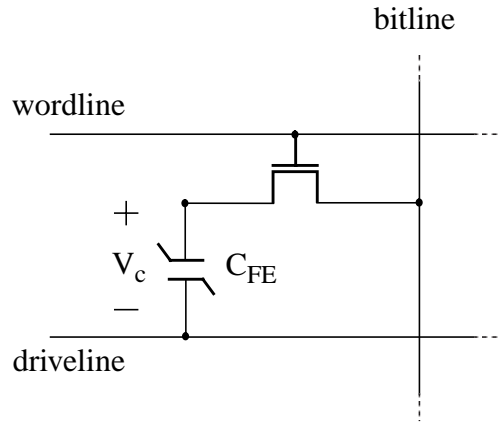


Figure 1: A 1T - 1C FRAM Cell

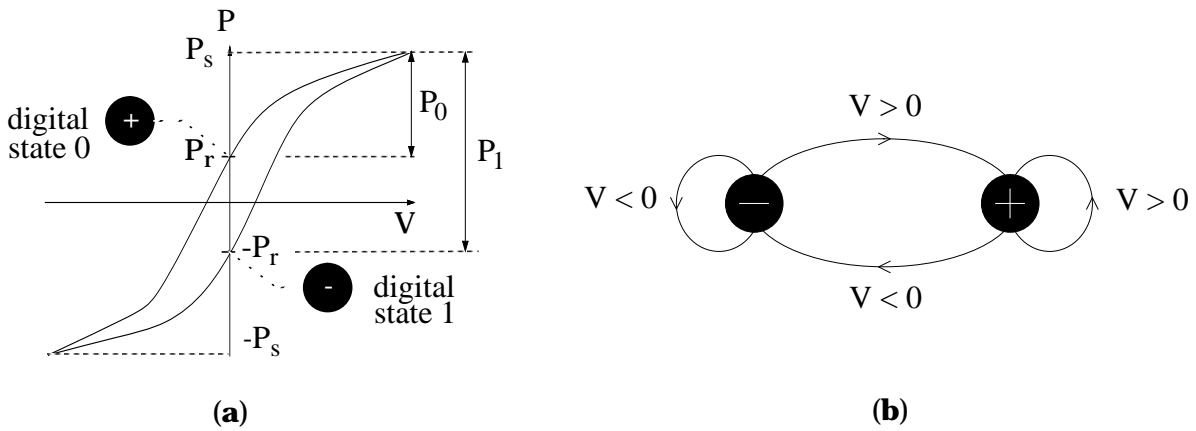


Figure 2: (a) Hysteresis Loop employed as a polarization state diagram, (b) State Transition Diagram for a two-state capacitor model

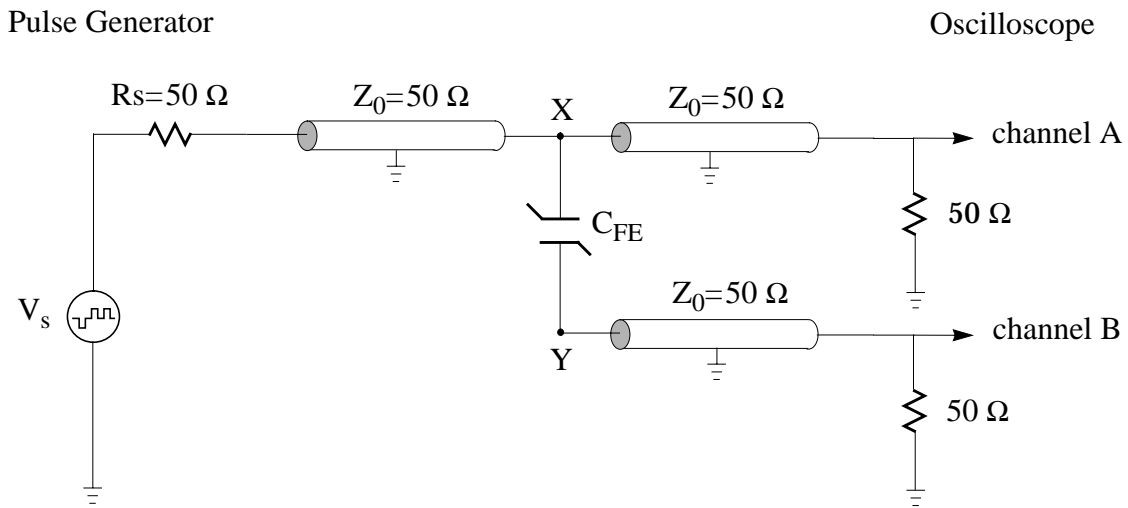


Figure 3: Pulse measurement circuit diagram

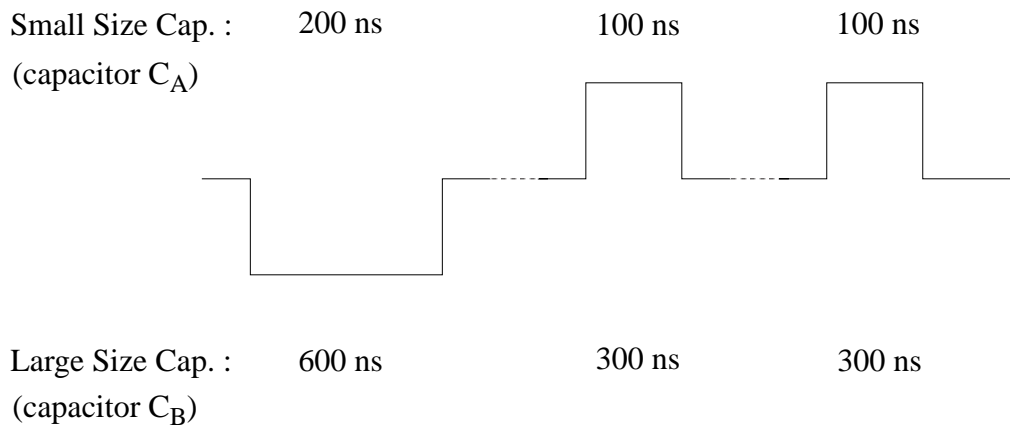


Figure 4: The pulse pattern applied to the pulse measurement circuit (Fig. 3). The dotted lines represent several seconds of delay between two consecutive pulses, as required to setup the instruments for each measurement.

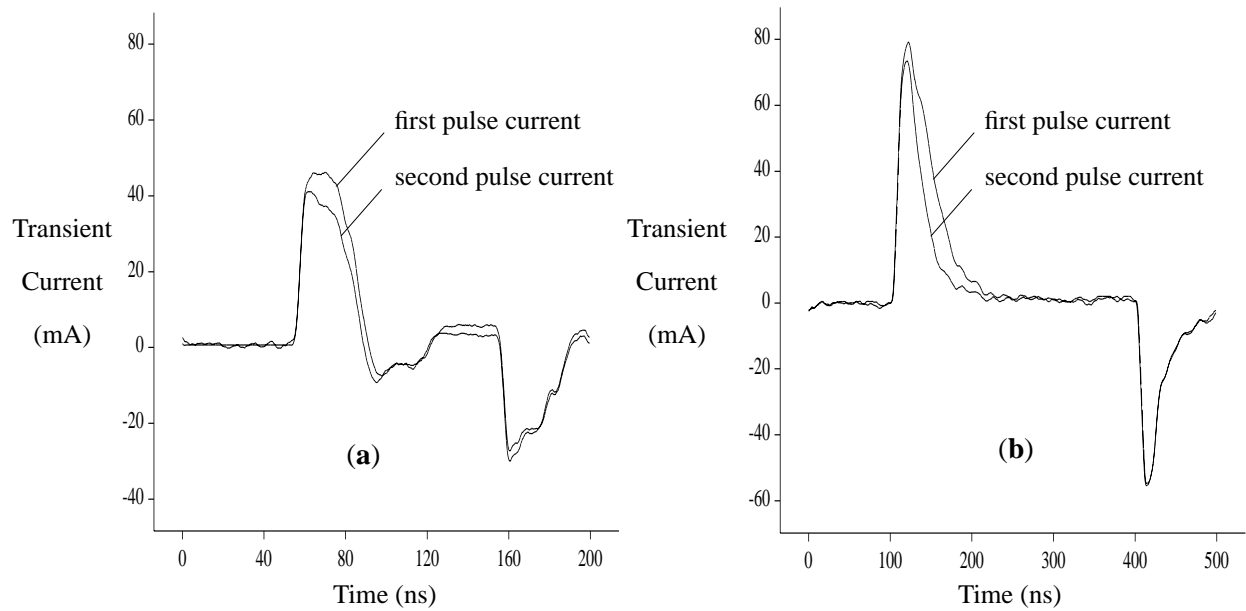


Figure 5: The transient currents associated with the first and second positive pulses (Fig. 4) for capacitors (a) C_A and (b) C_B .

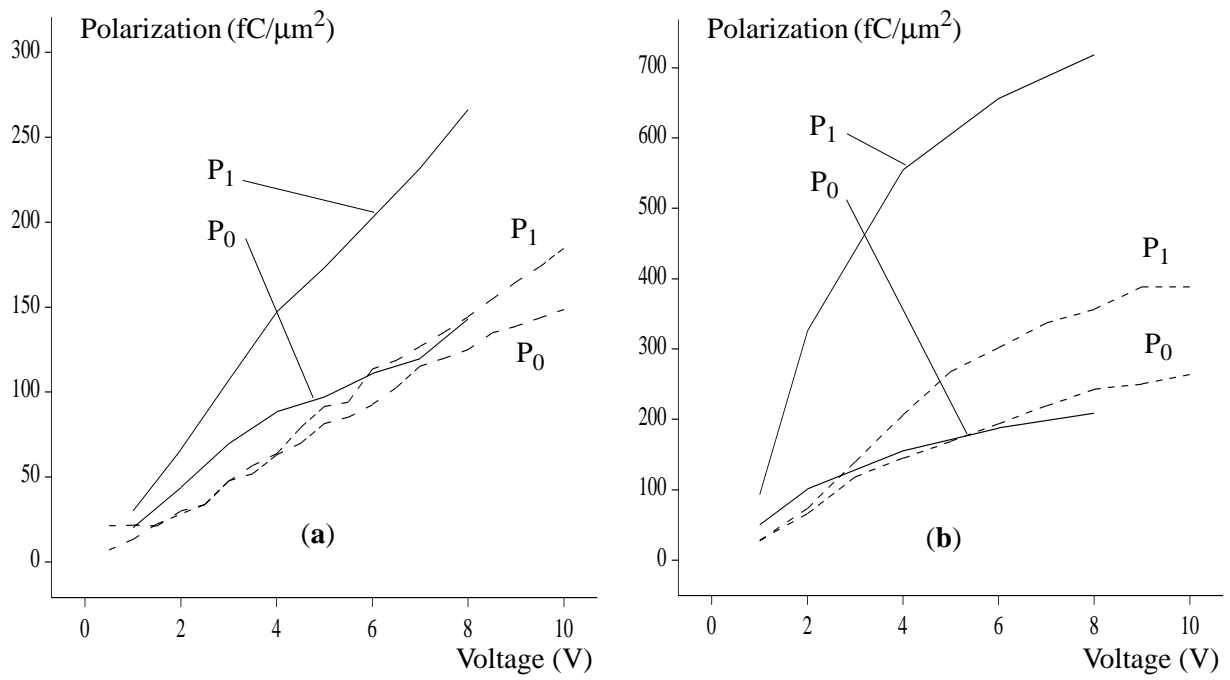


Figure 6: Hysteresis loop based polarizations (solid curves) versus the transient based polarizations (dashed curves) for capacitors (a) C_A and (b) C_B.

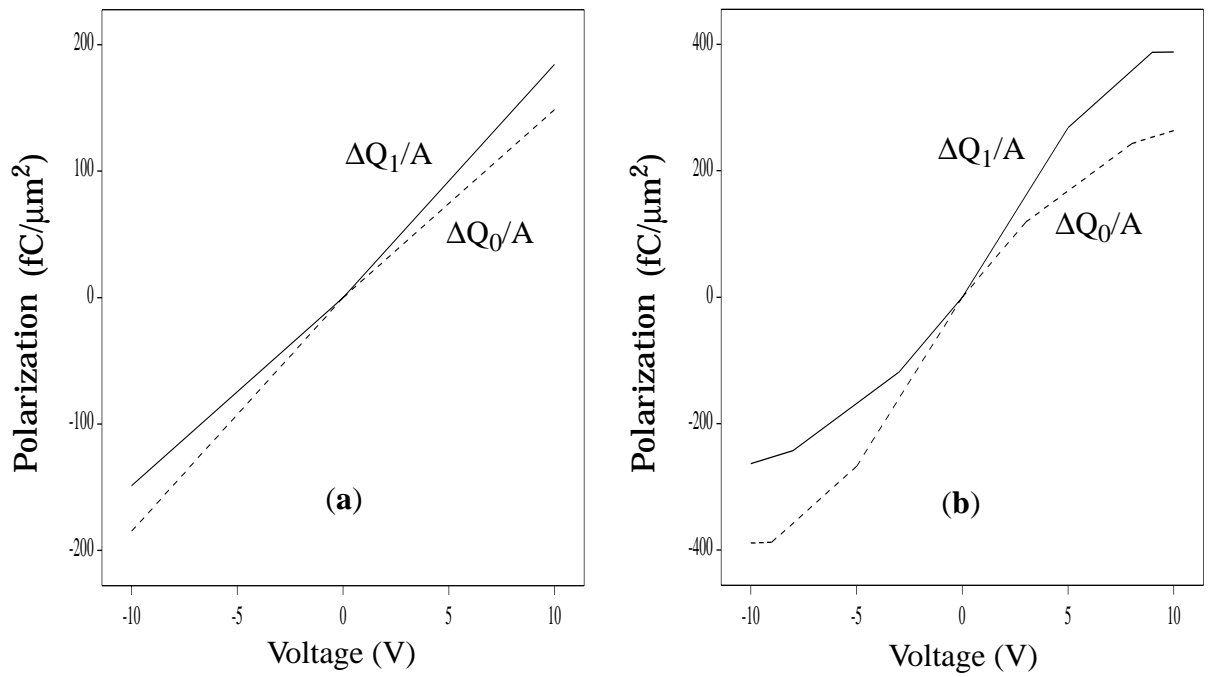


Figure 7: The characteristics of the two nonlinear capacitors representing capacitors (a) C_A and (b) C_B in the ZSTT Model.

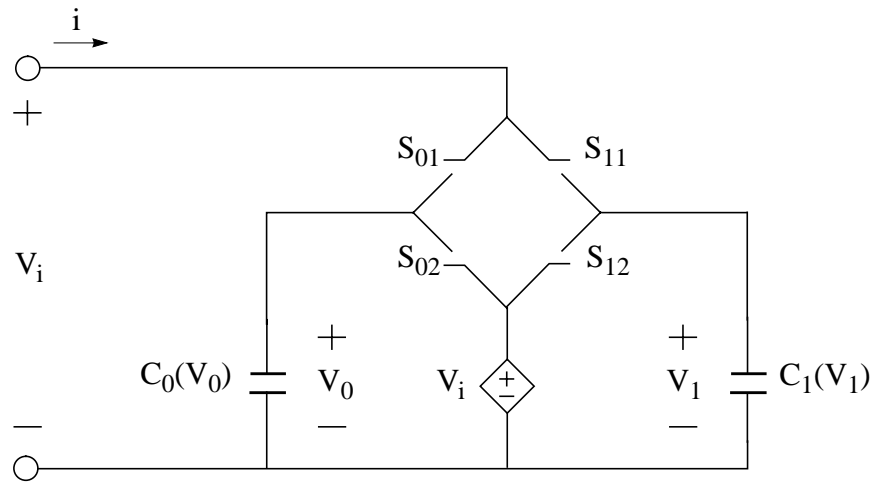


Figure 8: An implementation of the ZSTT Model.

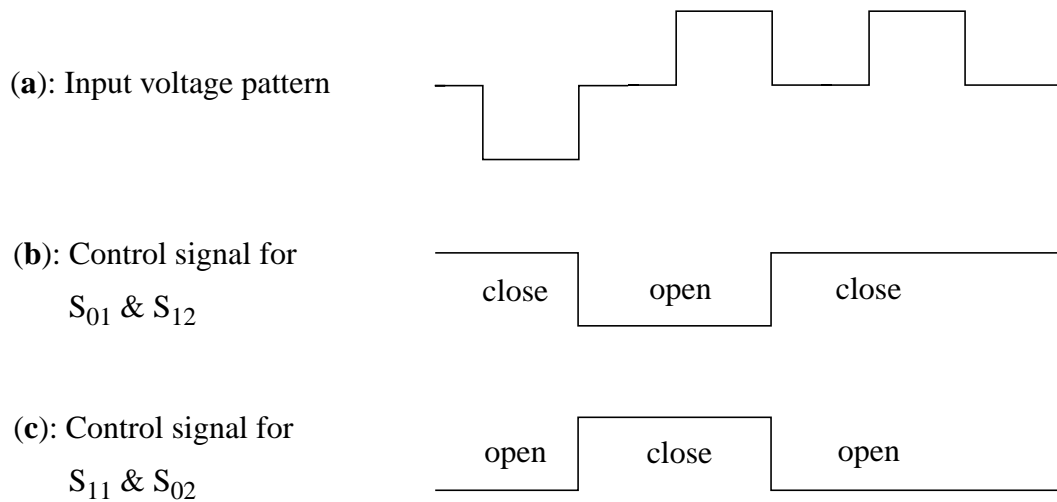


Figure 9: A sample voltage pattern across the FE capacitor and its corresponding control signals for switches in the ZSTT Model.

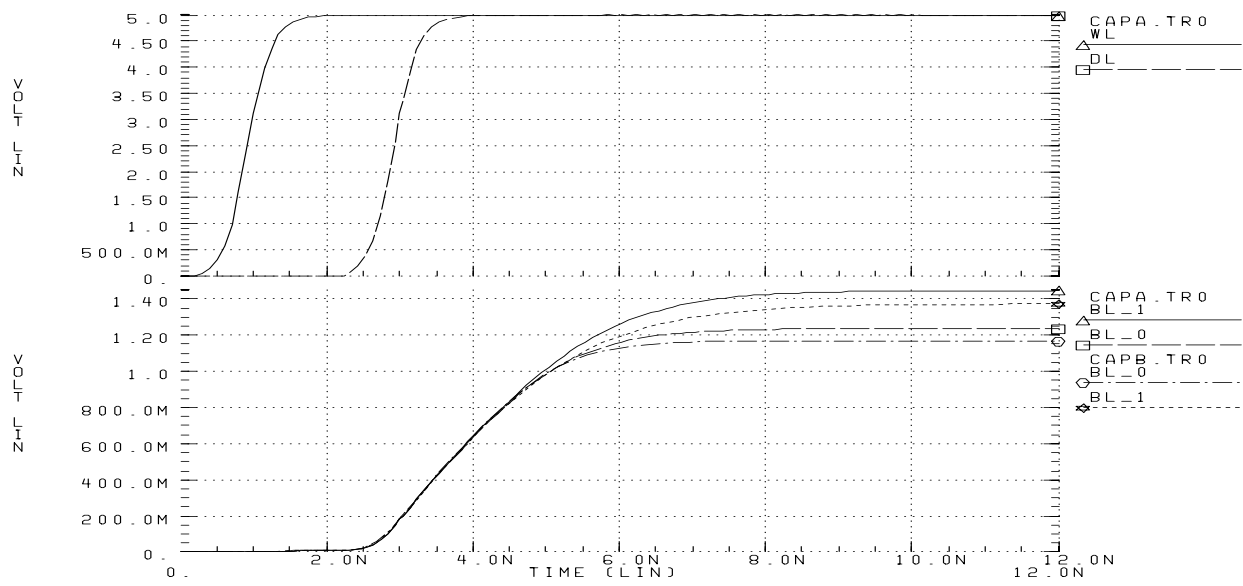


Figure 10: HSPICE simulation results for the read operation of a 1pF-bitline FRAM using optimized sizes of capacitors C_A and C_B